


# Normal-Metal–Superconductor Near-Field Thermal Diodes and Transistors

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In recent years there has been a number of proposals of thermal devices operating in the near-field regime that make use of phase-transition materials. Here, we present a theoretical study of near-field thermal diodes and transistors that combine superconducting materials with normal (nonsuperconducting) metals. To be precise, we show that a system formed by two parallel plates made of Nb and Au can exhibit unprecedented rectification ratios very close to unity at temperatures around the Nb superconducting critical temperature and for a wide range of gap size values within the near-field regime. Moreover, we also show that a superconducting Nb layer placed between Au plates can operate as a near-field thermal transistor where the amplification factor can be greatly tuned by varying different parameters such as the temperature and thickness of the Nb layer or the distance between the Nb layer and the Au plates. Overall, our work shows the potential of the use of superconductors for the realization of near-field thermal devices.

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## I. INTRODUCTION

When two objects at different temperatures are separated by a distance smaller than the thermal wavelength given by Wien's displacement law (approximately  $10\ \mu\text{m}$  at room temperature), they can exchange thermal radiation via evanescent waves (or photon tunneling). Such a contribution to the near-field radiative heat transfer (NFRHT) can dominate the heat exchange for small gaps and lead to overcoming the blackbody limit set by Stefan-Boltzmann's law for the radiative heat transfer between two bodies [1–3]. This NFRHT enhancement was predicted by Polder and van Hove in the early 1970s [4], making use of the so-called theory of fluctuational electrodynamics [5,6]. In recent years this idea has been thoroughly tested and confirmed in a great variety of systems and using different types of materials [7–31].

It is safe to say that at this stage the basic physical mechanisms underlying NFRHT are relatively well understood. For this reason, efforts in the thermal radiation community are now shifting towards the proposal and realization of novel functional devices based on NFRHT. In this regard, a natural research line that is being pursued is the investigation of the near-field thermal analogues of the key building blocks of today's microelectronics: diodes,

transistors, switches, memory elements, etc. Thus far, the diode or rectifier has been the most widely studied thermal device. There have been a lot theoretical proposals to achieve thermal rectification that make use of systems with dissimilar materials that, in turn, exhibit optical properties that depend on temperature. The proposed material combinations include SiC structures [32], doped Si films [33], dielectric coating [34], and Si and a different material [35], just to mention a few. However, the most promising proposals for near-field thermal diodes are based on the use of phase-transition materials [36–42]. An ideal example is that of vanadium dioxide ( $\text{VO}_2$ ), which undergoes a phase transition from insulator below 340 K to a metal above that temperature. This phase transition is accompanied by a drastic change in the infrared optical properties, which has a strong impact on the corresponding radiative heat transfer in systems featuring this material as the temperature is varied across the transition temperature [43–45]. In fact, several experiments have already demonstrated rectification between  $\text{VO}_2$  and  $\text{SiO}_2$  in the far-field regime [15,45,46]. More importantly for our work, the observation of thermal rectification in the near-field regime has recently been reported between a Si microdevice and a macroscopic  $\text{VO}_2$  film [47]. In that work, a clear rectifying behavior that increased at nanoscale separations was observed with a maximum rectification ratio exceeding 50% at about 140 nm gaps and a temperature difference of 70 K. This high rectification ratio was attributed to the

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broadband enhancement of heat transfer between metallic VO<sub>2</sub> and doped Si surfaces, as compared to the narrower-band exchange that occurs when VO<sub>2</sub> is in its insulating state. From the theoretical point of view, it has been shown that the rectification ratio can be boosted by nanostructuring VO<sub>2</sub> films to form, e.g., one-dimensional gratings, [41,48] and the highest reported values for the rectification ratio in the near-field reach about 94% [41].

In 2014, Ben-Abdallah and Biehs [49] extended the idea of thermal diodes based on a phase-transition material to propose the realization of a near-field thermal transistor. Their proposed transistor featured a three-body system (two diodes in series) in which a layer of a metal-to-insulator transition material (the gate) is placed at sub-wavelength distances from two thermal reservoirs (the source and the drain). In this device, the temperatures of the reservoirs are kept fixed, while the temperature of the gate is modulated around its steady-state temperature. Making use of an extension of the theory of fluctuational electrodynamics to deal with extended many-body systems [50], Ben-Abdallah and Biehs showed that, by changing the gate temperature around its critical value, the heat flux exchanged between the hot body (source) and the cold body (drain) can be reversibly switched, amplified, and modulated by a tiny action on the gate. We also note that these ideas have been extended to propose other key elements such as a thermal memory [51], and it has also been shown that thermal logic gates can be realized exploiting the near-field radiative interaction in  $N$ -body systems with phase-transition materials [52]. These proposals are nicely reviewed in Refs. [3,53].

Since phase-transition materials are ideally suited for near-field thermal management devices, it is natural to think of superconductors. Although superconductors work at low temperatures, their use has the advantage that, since the thermal wavelength is inversely proportional to temperature, the near-field regime extends to gaps beyond the millimeter scale for temperatures around 1 K. Thus, it is easy to reach gaps or separations for which the radiative heat transfer is enhanced beyond the blackbody limit. When a normal metal undergoes a superconducting phase transition (we focus here on conventional low-temperature superconductors), its optical properties change drastically in the microwave range due to the appearance of a gap in its density of states (of the order of 1 meV depending on the superconductor). This gap reduces the emissivity of the metal and in the superconducting state, one expects a substantial reduction of the NFRHT when a second material is brought in close proximity. This naive idea has been experimentally confirmed in recent years with measurements of the NFRHT between parallel plates made of superconductors like Nb and NbN [54,55]. In particular, it has been reported that there is a contrast in the NFRHT between the normal and superconducting states of a factor 5 in the case of Nb [54] and 8 in the case of NbN plates [55]. Inspired by

these experiments, Ordoñez-Miranda *et al.* [56] proposed the use of a low-temperature superconductor to realize a near-field thermal diode. In their proposal, the thermal reservoirs were made of Nb and SiO<sub>2</sub> and the device operated at temperatures around the superconducting critical temperature of Nb (9 K). In particular, they found that at temperatures of 1 and 8.7 K for the two thermal reservoirs, the rectification factor reached a maximum of 71% for gaps of the order of 60  $\mu$ m, which is quite high, but still below what is found in proposals involving vanadium dioxide. One the goals of this work is to theoretically show that the use of normal metals, instead of dielectrics like silica, can boost the performance of near-field thermal diodes comprising superconducting materials, even beyond any reported value in VO<sub>2</sub>-based thermal diodes. To be precise, we consider an Au-Nb rectifier [see Fig. 1(b)] and show that rectification ratios very close to unity are achieved in a very wide range of gap size values in the near-field regime. On the other hand, we also show that a Nb plate (the gate reservoir) placed in the middle of a vacuum gap between two Au plates [see Fig. 1(c)] can behave as a near-field transistor with amplification factors that can be largely tuned by varying different parameters, such as the temperature and thickness of the gate or the distance between the gate and the source and drain reservoirs.

The rest of the paper is organized as follows. In Sec. II we introduce the different systems and devices that we analyze in this work and explain how we model the optical properties of the materials involved in these systems (Nb and Au). In Sec. III we briefly discuss the radiative heat transfer between two parallel plates made of Nb to illustrate the impact of the superconducting phase transition in the heat exchanged via radiation. Then, Sec. IV is devoted to the analysis of the radiative heat rectification in a thermal diode made of Au and Nb parallel plates. In Sec. V we study the operation of a three-body system made of a Nb layer between two Au plates as a near-field thermal transistor. Finally, we summarize our main conclusions in Sec. VI.

## II. SYSTEMS AND OPTICAL PROPERTIES

As explained in the Introduction, the main goal of this work is to theoretically study the performance of near-field thermal diodes and transistors that make use of superconducting materials. To this end, we first briefly analyze the impact of the superconducting phase transition in the NFRHT in the case of two Nb parallel plates [see Fig. 1(a)], in which we consider temperatures below and above the superconducting critical temperature of Nb,  $T_C = 9$  K. The near-field diode that we investigate is schematically depicted in Fig. 1(b) and it consists of two infinite parallel plates made of Au and Nb separated by a gap of size  $d$ . Finally, the near-field transistor that we analyze in detail is shown in Fig. 1(c). In this case, a Nb

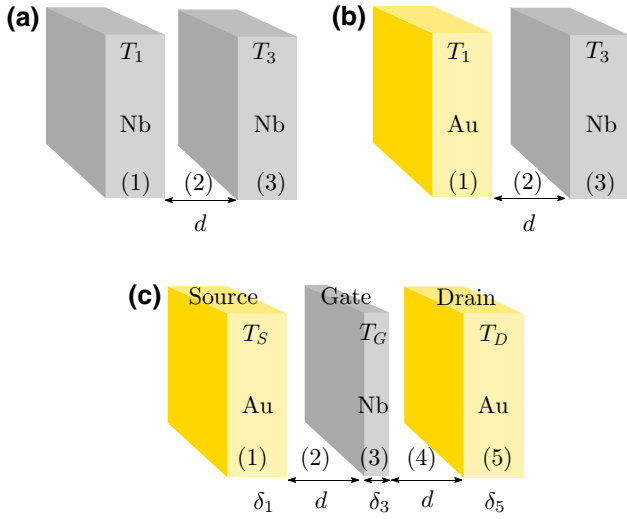


FIG. 1. Schematic representation of the three systems considered in this paper. The first system [panel (a)] consists of two infinite plates made of the superconducting material Nb, each with respective temperatures  $T_1$  and  $T_3$ , separated by a vacuum gap of size  $d$ . The second system [panel (b)] is a rectifier composed of a Nb infinite plate exchanging radiative heat with an infinite Au plate separated by a distance  $d$ . Finally, in panel (c), we display a near-field thermal superconducting transistor. The source and drain, each with fixed temperatures  $T_S$  and  $T_D$ , respectively, are assumed to be two infinite Au slabs ( $\delta_1 = \delta_5 = \infty$ ), whereas the gate is made of Nb, which undergoes a normal-superconducting phase transition at a critical temperature,  $T_C$ , as its temperature,  $T_G$ , is varied.

layer of thickness  $\delta_3$ , referred to as the gate, is placed in the middle of the vacuum gap between two infinite parallel plates made of Au, referred to as the source and drain. The temperatures of the source, drain, and gate are denoted by  $T_S$ ,  $T_D$ , and  $T_G$ , respectively, and we assume that  $T_S > T_D$ . The distance between the gate and the source and drain is denoted by  $d$  and we consider temperatures around (both above and below)  $T_C$ .

The analysis of the radiative heat transfer in all the cases shown in Fig. 1 will be done within the framework of the theory of fluctuational electrodynamics [5,6]. In this theory, and within the standard local approximation, the optical properties of the materials are fully determined by their frequency-dependent dielectric functions (we only consider here nonmagnetic materials). In what follows, we describe how we model the dielectric functions of the two materials involved in our systems under study, Nb and Au.

The Nb dielectric function is described here following Ref. [57] that, in turn, makes use of the Mattis and Bardeen theory for diffusive superconductors of arbitrary purity [58]. This dielectric function is given by

$$\epsilon_{\text{Nb}}(\omega) = \epsilon_{\infty, \text{Nb}} + \frac{4\pi i}{\omega} \sigma(\omega), \quad (1)$$

where  $\epsilon_{\infty, \text{Nb}}$  is the high frequency limit for the permittivity,  $\sigma(\omega)$  is the optical conductivity,  $\tau = \sigma_{\text{dc}}/(\epsilon_0 \omega_p^2)$  is the relaxation time,  $\epsilon_0$  is the vacuum permittivity, and  $\omega_{p, \text{Nb}}$  is the plasma frequency. In the superconducting state, the optical conductivity is given by [57]

$$\sigma_{\text{SC}}(\omega) = \frac{i\sigma_{\text{dc}}}{2\omega\tau} \left( J(\omega) + \int_{\Delta}^{\infty} I_2 d\varepsilon \right) \quad (2)$$

with

$$J(\omega) = \begin{cases} \int_{\Delta}^{\hbar\omega+\Delta} I_1 d\varepsilon, & \hbar\omega \leq 2\Delta, \\ \int_{\Delta}^{\hbar\omega-\Delta} I_3 d\varepsilon + \int_{\hbar\omega-\Delta}^{\hbar\omega+\Delta} I_1 d\varepsilon, & \hbar\omega \geq 2\Delta, \end{cases} \quad (3)$$

and

$$I_1 = \left[ \left( 1 - \frac{\Delta^2 + \varepsilon(\varepsilon - \hbar\omega)}{p_4 p_2} \right) \frac{1}{p_4 + p_2 + i\hbar/\tau} - \left( 1 + \frac{\Delta^2 + \varepsilon(\varepsilon - \hbar\omega)}{p_4 p_2} \right) \frac{1}{p_4 - p_2 + i\hbar/\tau} \right] \times \tanh\left(\frac{\varepsilon}{2kT}\right), \quad (4a)$$

$$I_2 = \left[ \left( 1 + \frac{\Delta^2 + \varepsilon(\varepsilon + \hbar\omega)}{p_1 p_2} \right) \frac{1}{p_1 - p_2 + i\hbar/\tau} - \left( 1 - \frac{\Delta^2 + \varepsilon(\varepsilon + \hbar\omega)}{p_1 p_2} \right) \frac{1}{-p_1 - p_2 + i\hbar/\tau} \right] \times \tanh\left(\frac{\varepsilon + \hbar\omega}{2kT}\right) \quad (4b)$$

$$+ \left[ \left( 1 - \frac{\Delta^2 + \varepsilon(\varepsilon + \hbar\omega)}{p_1 p_2} \right) \frac{1}{p_1 + p_2 + i\hbar/\tau} - \left( 1 + \frac{\Delta^2 + \varepsilon(\varepsilon + \hbar\omega)}{p_1 p_2} \right) \frac{1}{p_1 - p_2 + i\hbar/\tau} \right] \times \tanh\left(\frac{\varepsilon}{2kT}\right), \quad (4c)$$

$$I_3 = \left[ \left( 1 - \frac{\Delta^2 + \varepsilon(\varepsilon - \hbar\omega)}{p_3 p_2} \right) \frac{1}{p_3 + p_2 + i\hbar/\tau} - \left( 1 + \frac{\Delta^2 + \varepsilon(\varepsilon - \hbar\omega)}{p_3 p_2} \right) \frac{1}{p_3 - p_2 + i\hbar/\tau} \right] \times \tanh\left(\frac{\varepsilon}{2kT}\right), \quad (4d)$$

where

$$\begin{aligned} p_1 &= \sqrt{(\varepsilon + \hbar\omega)^2 - \Delta^2}, \\ p_2 &= \sqrt{\varepsilon^2 - \Delta^2}, \\ p_3 &= \sqrt{(\varepsilon - \hbar\omega)^2 - \Delta^2}, \\ p_4 &= i\sqrt{\Delta^2 - (\varepsilon - \hbar\omega)^2}. \end{aligned}$$

In these expressions,  $\varepsilon$  is the energy of the carriers,  $\omega$  is the frequency of electromagnetic waves,  $T$  is the temperature, and  $\Delta$  is the superconducting gap, whose temperature dependence is approximately described by [59]

$$\Delta(T) = \Delta_0 \left(1 - \frac{T}{T_C}\right)^{1/2} \left(0.9663 + 0.7733 \frac{T}{T_C}\right), \quad (5)$$

where  $T_C$  is the critical temperature. In the normal state ( $T > T_C$ ), the corresponding optical conductivity is given by [57]

$$\sigma_n(\omega) = \frac{\sigma_{dc}}{1 - i\omega\tau}. \quad (6)$$

To describe the Au layers, we use the following Drude-like relative permittivity [60]:

$$\epsilon_{Au} = \epsilon_{\infty,Au} - \frac{\omega_{p,Au}^2}{\omega(\omega + i\gamma_{Au})}. \quad (7)$$

Here  $\epsilon_{\infty,Au}$ ,  $\omega_{p,Au}$ , and  $\gamma_{Au}$ , are respectively the high frequency limit of the dielectric function, the plasma frequency, and the damping of the free carrier.

All calculations in this work are performed with the following parameters for Nb:  $\epsilon_{\infty,Nb} = 4$  [57],  $\Delta_0 = 1.764k_B T_C$ ,  $T_C = 9$  K,  $\sigma_{dc} = 1.7 \times 10^7$  S/m, and  $\omega_p = 8.8 \times 10^{15}$  rad/s [54]. For the Au layers,  $\epsilon_{\infty,Au} = 4$ ,  $\omega_{p,Au} = 1.71 \times 10^{16}$  rad/s, and  $\gamma_{Au} = 1.22 \times 10^{14}$  rad/s. These parameters are consistent with the experimental parameters reported in Ref. [61] for cryogenic temperatures. In Fig. 2 we display the frequency dependence of the real and imaginary parts of the dielectric functions of Nb and Au computed with these parameter values. In particular, we show the Nb dielectric function for different temperatures inside the superconducting phase, as well as for temperatures above  $T_C$ , i.e., in the normal state.

### III. Nb PARALLEL PLATES

Before discussing the functional devices, diode and transistor, it is convenient to analyze the impact of the superconducting phase transition in the NFRHT. To this end, we revisit here the case of two Nb parallel plates [see Fig. 1(a)], which has been analyzed, both theoretically and experimentally, in Ref. [54]. Within the theory of fluctuational electrodynamics, the net power per unit area (heat

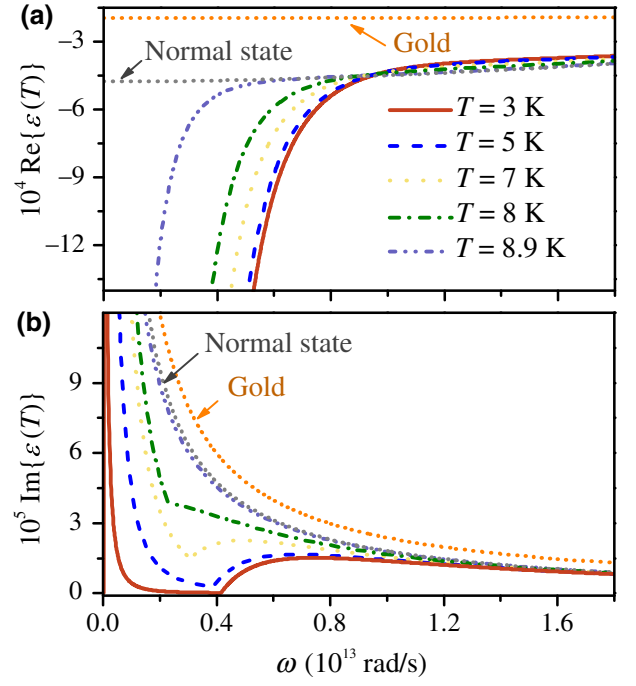


FIG. 2. Real (a) and imaginary (b) parts of the dielectric functions of Nb [see Eq. (1)] and Au [see Eq. (7)] employed in this work. The dielectric function of Nb is shown for different temperatures in the superconducting phase, as well as in the normal state.

flux) exchanged via radiation by two infinite parallel plates [see Fig. 1(a)] is given by [4]

$$Q = \int_0^\infty \frac{d\omega}{2\pi} [\Theta_1(\omega) - \Theta_3(\omega)] \int_0^\infty \frac{dk}{2\pi} k [\tau_s^{13} + \tau_p^{13}], \quad (8)$$

where  $\Theta_i(\omega) = \hbar\omega / [\exp(\hbar\omega/k_B T_i) - 1]$ ,  $T_i$  is the absolute temperature of layer  $i$ ,  $\omega$  is the radiation frequency,  $k$  is the magnitude of the wave vector parallel to the surface planes, and  $\tau_\beta^{13}(\omega, k, d)$  is the total transmission probability of the electromagnetic propagating ( $k < \omega/c$ ) and evanescent ( $k > \omega/c$ ) waves, given by

$$\tau_\beta^{13}(\omega, k, d) = \begin{cases} \frac{(1 - |r_\beta^{21}|^2)(1 - |r_\beta^{23}|^2)}{|1 - r_\beta^{21} r_\beta^{23} e^{2iq_2 d}|^2}, & k < \omega/c, \\ \frac{4\text{Im}(r_\beta^{21})\text{Im}(r_\beta^{23})e^{-2\text{Im}(q_2)d}}{|1 - r_\beta^{21} r_\beta^{23} e^{2iq_2 d}|^2}, & k > \omega/c. \end{cases} \quad (9)$$

Here,  $q_i = \sqrt{\epsilon_i \omega^2 / c^2 - k^2}$  is the wave vector component perpendicular to the plate surfaces in the vacuum gap and  $c$  is the velocity of light in vacuum. The reflection

amplitudes  $r_{\beta}^{ij}$  are given by the Fresnel coefficients

$$r_s^{ij} = \frac{q_i - q_j}{q_i + q_j} \quad \text{and} \quad r_p^{ij} = \frac{\epsilon_j q_i - \epsilon_i q_j}{\epsilon_j q_i + \epsilon_i q_j}. \quad (10)$$

The corresponding linear thermal conductance per unit of area, usually referred to as the heat transfer coefficient, is given by

$$h = \int_0^{\infty} \frac{d\omega}{2\pi} \frac{\partial}{\partial T} \left[ \frac{\hbar\omega}{e^{\hbar\omega/k_B T} - 1} \right] \int_0^{\infty} \frac{dk}{2\pi} k [\tau_s^{13} + \tau_p^{13}]. \quad (11)$$

In the case of two blackbodies, which is achieved when  $\tau_{\beta}^{ij} = 1$  for all frequencies for propagating waves, this result reduces to the Stefan-Boltzmann law

$$h_{\text{BB}} = 4\sigma T^3, \quad (12)$$

where  $\sigma$  is the Stefan-Boltzmann constant (not to be confused with a conductivity).

In Fig. 3(a) we show the results for the gap dependence of the heat transfer coefficient of two Nb parallel plates for different temperatures across the superconducting phase transition ( $T_C = 9$  K). One can see that the heat transfer coefficient is greatly enhanced in the near-field regime ( $d < 10^5$  nm) and it saturates for small gaps ( $d < 100$  nm). Note also that there is a pronounced temperature dependence, especially for temperatures below  $T_C$ . This strong dependence is due to both the impact of the superconducting phase transition and the fact that the temperature itself is being changed by an amount comparable to its absolute value. To disentangle those two dependencies, it is convenient to normalize the heat transfer coefficient by the corresponding result for two blackbodies, as we do in Fig. 3(b). With this normalization, we see that the blackbody limit is greatly overcome in the near-field regime (by almost 5 orders of magnitude at  $T \sim 10$  K and gaps  $d < 100$  nm). More importantly for this work, there is a very strong reduction of the NFRHT upon decreasing the temperature below  $T_C$ . For instance, for small gaps, the NFRHT for 3 K is about 10 times smaller than for 9.1 K. In simple terms, this dramatic effect can be explained by the presence of a gap in the spectrum of a superconductor that naturally leads to a strong reduction of the emissivity of the material at low frequencies; see Fig. 2(b). On the other hand, and in order to give an insight into the NFRHT in the superconducting phase, we show in Fig. 3(c) the gap dependence of the different contributions to the heat transfer coefficient for the Nb parallel plates for a temperature  $T = 7$  K, including both propagating and evanescent waves for both TE (or  $s$ ) and TM (or  $p$ ) waves. As expected for metals, the NFRHT is largely dominated by evanescent TE modes, which can be attributed to total internal reflection modes as explained in detail in Ref. [60].

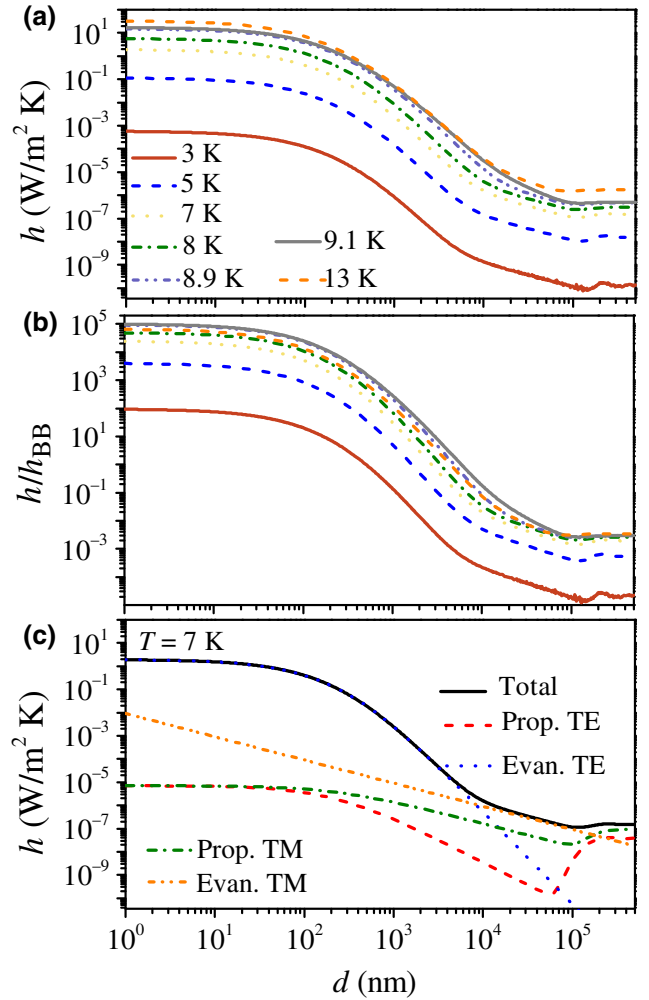


FIG. 3. (a) Heat transfer coefficient,  $h$ , for two Nb parallel plates [see Fig. 1(a)] as a function of the vacuum gap size  $d$ . The different curves correspond to different values of the average temperature of the reservoirs,  $T$ , whose temperature difference is assumed to be infinitesimal by definition. (b) The same as in (a), but now the heat transfer coefficient is normalized to the corresponding blackbody limit,  $h_{\text{BB}}$  [see Eq. (12)]. (c) Different contributions to the heat transfer coefficient of two Nb plates from both propagating and evanescent waves with TE and TM polarization and for a temperature of 7 K.

#### IV. NEAR-FIELD THERMAL RECTIFIER

Now we turn to the analysis of the thermal rectifier shown in Fig. 1(b) and composed of two parallel plates made of Nb and Au. As explained in the Introduction, there have been many proposals for near-field thermal rectifiers employing a variety of materials that undergo a phase transition as a function of temperature. In particular, Ordoñez-Miranda *et al.* [56] proposed a diode with terminals made of parallel plates of Nb and  $\text{SiO}_2$  and operating at temperatures between 1 and 8.7 K, for which Nb is superconducting. These authors reported that the rectification factor (see the definition below) could reach 71%



for gaps of the order of  $60 \mu\text{m}$ . In what follows, we show that the performance of a superconducting near-field thermal rectifier can be boosted by using a metal as a second thermal reservoir instead of a polar dielectric like silica.

The heat flux in an asymmetric system like that of Fig. 1(b) can be calculated with the formulas described in the previous section. For the rectifying behavior, we calculate the net heat flux for both forward bias (FB) and reverse bias (RB) configurations. The forward (reverse) bias heat flux,  $Q_{\text{FB}}$  ( $Q_{\text{RB}}$ ), is calculated by setting  $T_1 = 1$  K and  $T_3 = T_1 + \Delta T$  with  $\Delta T > 0$  ( $T_1 = T_3 + \Delta T$  and  $T_3 = 1$  K), i.e., in forward (reverse) bias the temperature gradient is from media (1) to (3) [(3) to (1)]. The rectification factor is defined as

$$\eta = \left| \frac{|Q_{\text{FB}}| - |Q_{\text{RB}}|}{\max(|Q_{\text{FB}}|, |Q_{\text{RB}}|)} \right|. \quad (13)$$

Note that, with this definition,  $\eta$  is bounded between 0 and 1.

In Fig. 4 we summarize our main results for the thermal diode of Fig. 1(b). In the upper panel we show the forward and reverse bias heat fluxes for  $d = 10$  nm as a function of the temperature difference  $|\Delta T|$ , while the temperature of the coldest plate is fixed at 1 K. The corresponding rectification factor is also shown. Note that very high values above 0.9 can be achieved for small values of the temperature difference. In the lower panel we show the results for the gap dependence of the rectification factor for various temperature differences. As one can see, very high values are reached in the near-field regime in a huge range of gap size values (of about four decades). In particular, values as high as 98.7% are obtained for gaps of the order of  $10 \mu\text{m}$  [see Fig. 4(b)], which are among the highest ever reported in extended systems and, in particular, are much higher than those predicted in previous proposals of superconducting thermal rectifiers [56]. We note that it has recently been predicted that rectification ratios very close to 1 could be achieved in the near-field regime using individual nanoparticles made of intrinsic silicon and a dissimilar material [62]. However, this proposal requires a huge temperature difference (about 700 K) and particles so small (radii of about 10–20 nm) that it is currently impossible to explore experimentally.

To gain some physical insight into the origin of the huge rectification ratios in our system, we show in Fig. 5(a) the spectral heat flux (or power per unit of area and frequency) as a function of frequency for the forward and reverse biases for a case in which the temperatures of the cold and hot reservoirs are 1 and 8.9 K, respectively. In this case, the gap size is 10 nm. The spectral heat flux has the characteristic form in metallic systems in which the evanescent TE electromagnetic modes completely dominate the NFRHT [22,60], which is also the case in our asymmetric configuration. Note, in particular, that, for the reverse bias, there is

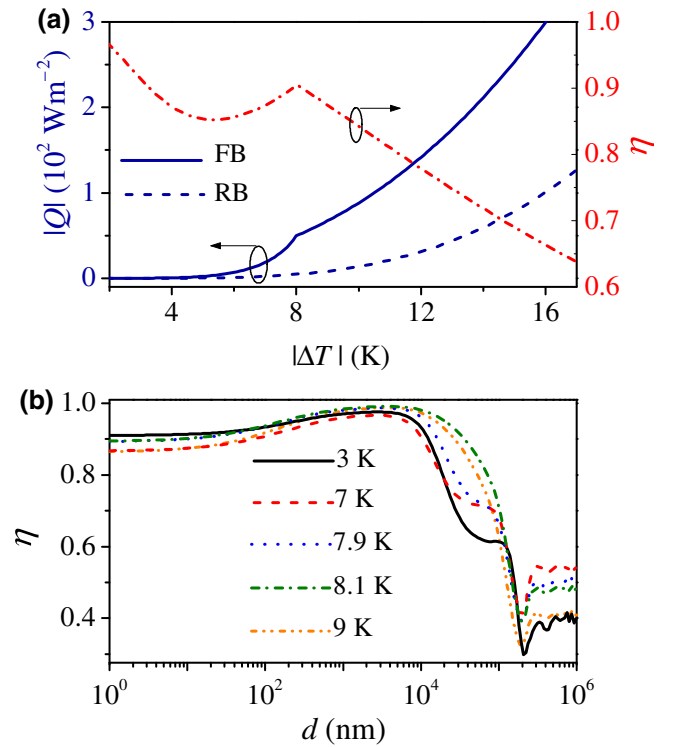


FIG. 4. (a) Forward and reverse bias radiative heat fluxes in the rectifier of Fig. 1(b) as a function of the temperature difference  $|\Delta T| = |T_1 - T_3|$  and for a gap size of 10 nm. The corresponding rectification factor  $\eta$ , defined in Eq. (13), is also included. (b) Rectification factor as a function of the vacuum gap size  $d$  and for different values of the temperature difference  $|\Delta T| = |T_1 - T_3|$ . All results are obtained for  $\min(T_1, T_3) = 1$  K.

an abrupt frequency cutoff below which the spectral function drastically drops. For the reverse bias, the Nb plate is at 1 K, i.e., deep into the superconducting phase, and that cutoff simply corresponds to the frequency  $\omega_0 = 2\Delta_0/\hbar \approx 4.2 \times 10^{12}$  rad/s that is required to break a Cooper pair. Below this frequency, the emissivity of the Nb plate is drastically reduced due to the presence of a gap in the electronic spectrum, which explains the strong reduction of the radiative heat transfer, as compared to the forward bias configuration. This interpretation is further illustrated in Figs. 5(b) and 5(c) where we show the corresponding transmission probability for the evanescent TE modes as a function of the frequency and the parallel component of the wave vector. Note that, for the reverse bias, panel (c), the transmission is very small below  $\omega_0$ . This fact, together with the frequency dependence of the thermal factor  $|\Theta_1(\omega) - \Theta_3(\omega)|$  [see the dotted lines in panels (b) and (c)] determining the electromagnetic modes available for heat transfer [see Eq. (8)], explains the huge difference in the net power between the reverse and forward bias configurations.

The discussion above also allows us to understand why in a superconducting rectifier it is advantageous to use

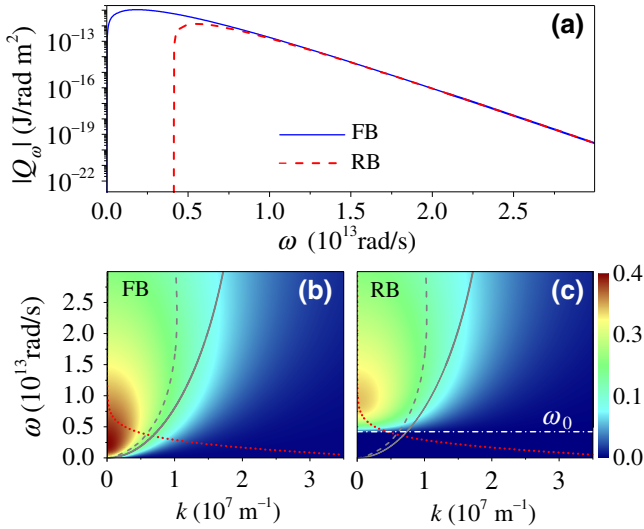


FIG. 5. (a) Spectral heat flux for the forward (solid line) and reverse (dashed line) bias configurations as a function of the frequency and parallel wave vector for a gap size of 10 nm in the system of Fig. 1(b). The temperature difference is set to  $|\Delta T| = |T_1 - T_3| = 7.9$  K, with a temperature of 1 K for the cold reservoir. (b),(c) The transmission probability of the evanescent TE modes corresponding to each configuration. The dashed and solid lines in both panels respectively represent the Nb and Au light lines  $\omega = ck\text{Re}(\epsilon_{\text{Nb}}^{1/2})$  and  $\omega = ck\text{Re}(\epsilon_{\text{Au}}^{1/2})$ , whereas the dotted line corresponds to the thermal factor  $|\Theta_1 - \Theta_3|$  shown here in arbitrary units. The dash-dot line in panel (c) indicates the photon frequency required to break a Cooper pair in the superconducting state,  $\omega_0 = 2\Delta_0/\hbar \approx 4.2 \times 10^{12}$  rad/s.

a metal like Au as a second reservoir instead of a polar dielectric like  $\text{SiO}_2$  as in Ref. [56]. First, as discussed above and illustrated in Fig. 5, the fact that, for the forward bias, both Nb and Au are basically normal metals makes the NFRHT be dominated by the contribution of relatively low frequencies. Thus, the existence of a gap in Nb in the reverse bias configuration, which suppresses the low-frequency heat transfer, has a particularly strong impact in the rectification ratio. This is much more dramatic than in the case of  $\text{SiO}_2$  because in this polar dielectric the heat transfer proceeds through phonon polariton resonances that appear at much higher frequencies. Additionally, since these polaritonic resonances are barely thermally occupied at cryogenic temperatures, the power exchanged between Nb and  $\text{SiO}_2$  at low temperatures is many orders of magnitude smaller than in our Nb-Au rectifier, which is another big advantage of our proposal.

## V. NEAR-FIELD THERMAL TRANSISTOR

Let us now analyze the superconducting thermal transistor depicted in Fig. 1(c) that features a Nb layer of thickness  $\delta_3$  as a gate electrode that is placed at a distance  $d$  from two Au plates that act as the source and drain.

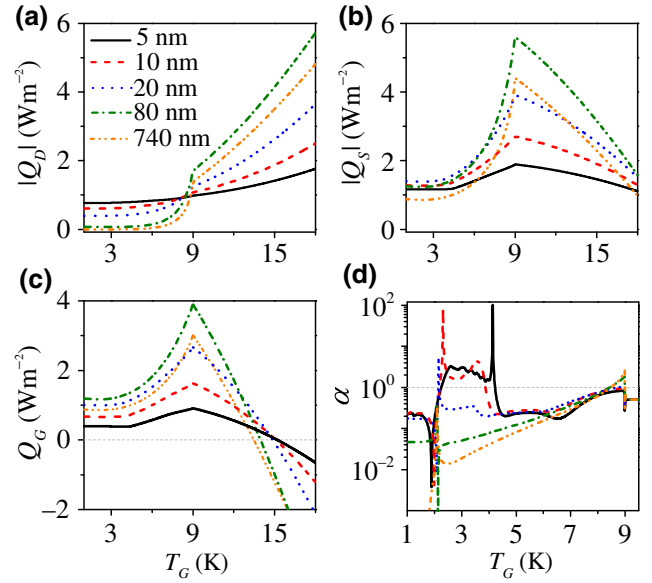


FIG. 6. (a) Absolute value of the radiative heat flux received by the drain in the thermal transistor of Fig. 1(c) as a function of the temperature of the gate. The different curves correspond to different values of the gate thickness  $\delta_3$ . (b) The corresponding absolute value of the heat flux lost by the source. (c) The corresponding net flux received or lost by the gate. (d) The corresponding amplification factor. All the results were obtained for a vacuum gap size of  $d = 500$  nm, and the source and drain temperatures are  $T_S = 20$  K and  $T_D = 1$  K, respectively.

To compute the different heat exchanges in this three-body system, we employ the many-body theory put forward in Ref. [50]. According to this theory, the heat flux received by the drain,  $Q_D$ , and the heat flux lost by the source,  $Q_S$ , in the near-field thermal transistor of Fig. 1(c) are given by

$$Q_D = \int_0^\infty \frac{d\omega}{2\pi} \sum_{\beta=s,p} \int_0^\infty \frac{dk}{2\pi} k [\Theta_{13} \tau_\beta^{13} + \Theta_{35} \tau_\beta^{35}], \quad (14)$$

$$Q_S = \int_0^\infty \frac{d\omega}{2\pi} \sum_{\beta=s,p} \int_0^\infty \frac{dk}{2\pi} k [\Theta_{53} \tau_\beta^{53} + \Theta_{31} \tau_\beta^{31}], \quad (15)$$

where  $\Theta_{ij} = \Theta_i(\omega) - \Theta_j(\omega)$  and  $\tau_\beta^{ij}$  is the transmission probability of electromagnetic waves from region  $i$  to  $j$  in Fig. 1(c). For a symmetric configuration (source and drain equidistant to the gate), as considered in this work, these transmissions probabilities are given by

$$\tau_\beta^{13} = \frac{4|\tau_\beta^3|^2 \text{Im}(\rho_\beta^1) \text{Im}(\rho_\beta^5) e^{-4\text{Im}(q_2)d}}{|1 - \rho_\beta^{13} \rho_\beta^5 e^{-2\text{Im}(q_2)d}|^2 |1 - \rho_\beta^1 \rho_\beta^3 e^{-2\text{Im}(q_2)d}|^2}, \quad (16)$$

$$\tau_\beta^{35} = \frac{4\text{Im}(\rho_\beta^{13}) \text{Im}(\rho_\beta^5) e^{-2\text{Im}(q_2)d}}{|1 - \rho_\beta^{13} \rho_\beta^5 e^{-2\text{Im}(q_2)d}|^2},$$

where

$$\begin{aligned}\rho_\beta^{13} &= \rho_\beta^3 + \frac{(\tau_\beta^3)^2 \rho_\beta^1 e^{-2\text{Im}(q_2)d}}{|1 - \rho_\beta^1 \rho_\beta^3 e^{-2\text{Im}(q_2)d}|^2}, \\ \rho_\beta^i &= -r_\beta^i \frac{1 - e^{2iq_i\delta_i}}{1 - (r_\beta^i)^2 e^{2iq_i\delta_i}}, \\ \tau_\beta^i &= \frac{t_\beta^i \bar{t}_\beta^i e^{iq_i\delta_i}}{1 - (r_\beta^i)^2 e^{2iq_i\delta_i}}, \\ r_s^j &= \frac{q_2 - q_i}{q_2 + q_i}, & r_p^j &= \frac{\epsilon_i q_2 - q_i}{\epsilon_i q_2 + q_i}, \\ t_s^j &= \frac{2q_2}{q_2 + q_i}, & t_p^j &= \frac{2\sqrt{\epsilon_i} q_2}{\epsilon_i q_2 + q_i}, \\ \bar{t}_s^j &= \frac{2q_i}{q_2 + q_i}, & \bar{t}_p^j &= \frac{2\sqrt{\epsilon_i} q_i}{\epsilon_i q_2 + q_i}.\end{aligned}$$

Additionally, the transmission probabilities  $\tau_\beta^{53}$  ( $\tau_\beta^{31}$ ) can be obtained after the substitutions  $1 \rightarrow 5$  and  $5 \rightarrow 1$  in  $\tau_\beta^{13}$  ( $\tau_\beta^{35}$ ). The corresponding net heat flux received or emitted by the gate is defined as [49]

$$Q_G = |Q_S| - |Q_D| \quad (17)$$

and the amplification factor as

$$\alpha = \left| \frac{\partial |Q_D|}{\partial Q_G} \right| = \frac{1}{|1 - Q'_S/Q'_D|}, \quad (18)$$

where  $Q'_{S/D} = \partial |Q_{S/D}| / \partial T_G$ . Amplification requires a negative differential conductance and it is characterized by  $\alpha > 1$  [49]. In what follows, we choose  $T_S = 20$  K,  $T_D = 1$  K, and  $T_S > T_G > T_D$ .

In Figs. 6(a)–6(c) we present the different powers gained or lost by the three thermal reservoirs (drain, source, and gate) as a function of the gate temperature  $T_G$  for different values of the gate thickness  $\delta_3$  and a Nb-Au gap  $d = 500$  nm. As expected, the heat received by the drain,  $|Q_D|$ , increases monotonically with  $T_G$ , irrespective of whether the gate is in the normal or superconducting state; see Fig. 6(a). On the other hand, and contrary to what one could naively expect, the heat lost by the source [see panel (b)] and the net heat in the gate [see panel (c)] do not decrease monotonically upon increasing  $T_G$ . This peculiar behavior only takes place in the superconducting state ( $T_G < T_C$ ) and it is a necessary condition for the amplification to occur; see Eq. (18). In Fig. 6(d) we show the corresponding value of the amplification factor, defined in Eq. (18), as a function of  $T_G$ . Note that, for thin Nb layers, values of  $\alpha$  larger than 1 are possible in a certain range of temperatures within the superconducting phase, and for very specific values of  $T_G$ , the amplification factor

can reach values close to 100. In those cases, our three-body system truly behaves as a near-field transistor. This is, however, never the case when the Nb gate is in its normal state where  $\alpha$  tends to  $\frac{1}{2}$ .

To gain some insight into the origin of the amplification, we show in Fig. 7(b) the derivatives of the heat exchanges in the source and drain with respect to the gate temperature,  $Q'_{S/D}$ , for the case of  $\delta_3 = 5$  nm shown in Fig. 6(d); see also Fig. 7(a). From Eq. (18) we see that amplification ( $\alpha > 1$ ) requires that  $1 < Q'_S/Q'_D < 2$ . The dependence with the gate temperature shown in Fig. 7(b) explains why there is amplification in the range between approximately 2.5 and 4.2 K and why there is a huge peak at around 4.2 K, which corresponds to the situation in which  $Q'_S \approx Q'_D$ . Moreover, we show in Fig. 7(b) the different individual contributions to  $Q'_S$  following Eq. (15). There we see that the key temperature dependence of  $Q'_S$  is mainly determined by the term involving  $\Theta_{31} \tau_s^{31}$  for TE (or  $s$ ) polarization, which is related to the heat lost by the source to the combined gate-drain system. To understand the  $T_G$  dependence of this term, we illustrate in Fig. 7(c) the evolution with the gate temperature of the corresponding spectral contribution. As one can see, the temperature dependence is only significant in the frequency region close to  $\omega_0 = 2\Delta_0/\hbar$  for the temperatures in which the amplification occurs. As we show in Fig. 7(d), that temperature dependence is much weaker

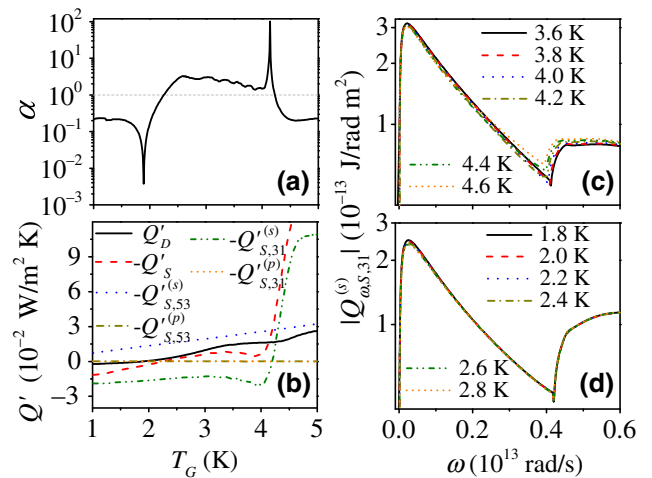


FIG. 7. (a) Amplification factor for a Nb gate with a thickness of 5 nm, separated from both the source and the drain by a 500 nm vacuum gap; see Fig. 6(d). (b) The corresponding derivatives of the heat received by the drain,  $Q'_D$ , and of the heat lost by the source,  $Q'_S$ . Also included are the derivatives of each of the terms contributing to the heat lost by the source; see Eq. (15). (c) Absolute value of the spectral heat flux  $Q_{\omega,S,31}^{(s)} = \Theta_{31} \tau_s^{31}$  for several temperatures around the maximum amplification region in (a). (d) The same as in (c) for a gate of thickness 10 nm, in the temperature region where the corresponding amplification reaches its maximum in Fig. 6(d).



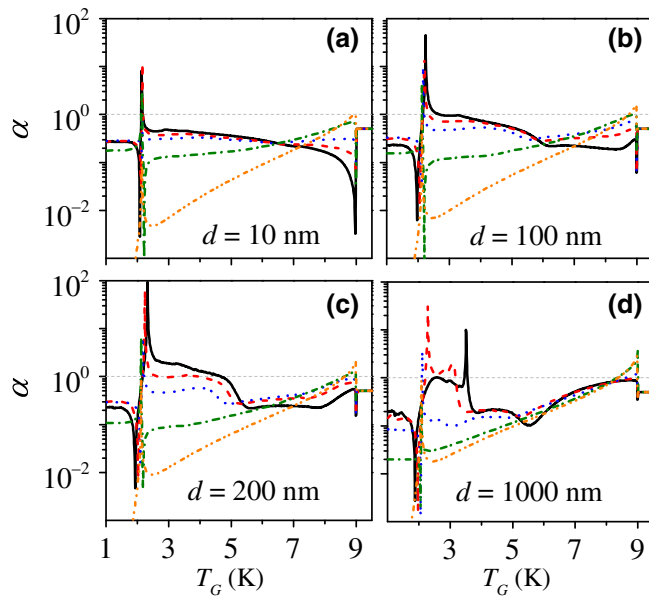


FIG. 8. Amplification factor in the thermal transistor of Fig. 1(c) as a function of gate temperature. The different panels correspond to different vacuum gap sizes, while the different curves in each panel correspond to different values of the gate thickness,  $\delta_3$ , whose values are the same as in Fig. 6. In all cases the source and drain temperatures are  $T_S = 20$  K and  $T_D = 1$  K, respectively.

when the gate thickness is increased, which explains why the amplification gets lost as the gate thickness increases.

For completeness, we have systematically explored the role of the gap size  $d$  between the Nb gate and the Au reservoirs. A summary of these results is given in Fig. 8 where we show the amplification factor as a function of the gate temperature for different values of  $d$  (and also different values of the gate thickness). As one can see, the optimal amplification occurs for gap sizes  $d$  of the order of a few hundred nanometers, while it only appears at some special points of the parameter space for smaller and larger gap values. In all cases, the amplification only appears for very thin Nb films.

## VI. CONCLUSIONS

Motivated by recent theoretical proposals and experiments on the use of phase-transition materials to realize near-field thermal devices that mimic electronic components, we have presented in this work a theoretical study of the performance of near-field thermal diodes and transistors based on the combination of superconductors and normal metals. We have shown that the drastic reduction in the thermal emission of a metal when it undergoes a superconducting transition can be utilized to realize heat rectification in two-body systems and heat amplification in three-body devices. In particular, we have shown that a system formed by two parallel plates made of Au and

(superconducting) Nb can act as a near-field thermal diode that exhibits striking rectification ratios very close to unity in a wide range of gap size values, outperforming all the existent proposals to date. Moreover, we have shown that a Nb layer placed in the middle of two Au plates can amplify the heat transferred to the drain at temperatures below the Nb critical temperature. The ideas put forward in this work can be extended to propose other functional devices, such as thermal logic gates, and, overall, they illustrate the potential of the use of superconducting materials for near-field thermal management at low temperatures.

## ACKNOWLEDGMENTS

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